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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Attorney Docket: SLA0786

Inventor: Pooran Joshi, et al.

Confirmation No. 2314

Serial No.: 10/812,591

Group #: 2891

Filed: March 29, 2004

Examiner: Asok K. Sarkar

Title: HIGH DENSITY PLASMA PROCESS FOR THE FORMATION OF  
SILICON DIOXIDE ON SILICON CARBIDE SUBSTRATESCommissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

## ASSOCIATE POWER OF ATTORNEY

## CHANGE OF CORRESPONDENCE ADDRESS

I hereby appoint Gerald Maliszewski, P. O. Box 270829 San Diego, CA 92198-29, U. S. Patent and Trademark Office Registration Number 38,054, as an associate attorney for the above-captioned matter, with full power of substitution and revocation, to prosecute this application and to transact all business in the Patent and Trademark Office connected therewith.

Please change the Correspondence address to that associated with Customer Number 55,286.

Date:

12/19/05

Respectfully submitted,

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